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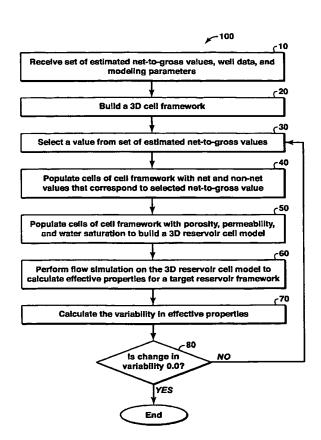
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(54) Title: RESERVOIR MODEL BUILDING METHODS



(57) Abstract: Disclosed are various reservoir model generation methods. At least one of the methods includes providing a first framework having a plurality of cells, wherein the first framework is a reservoir framework and providing a second framework having a plurality of cells, wherein the volume of the first framework is greater than the volume of the second framework.

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